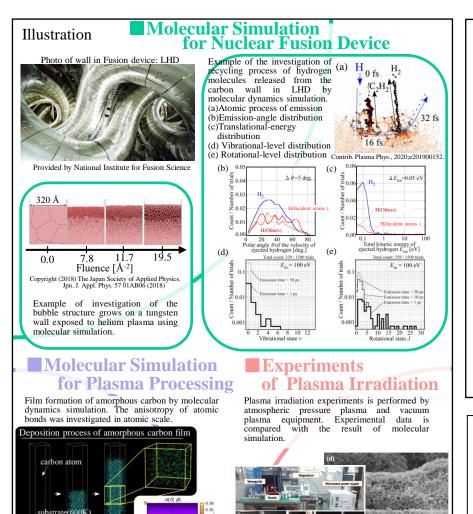
Molecular Simulation of Plasma-Material Interaction

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Content:

The complex physical phenomena caused on the interaction between plasma and materials are investigated.

Technologies that utilize the interaction between plasma and material spreads widely in our lives. For example, plasma processing technology is employed for the fabrication of semiconductor and thin film that support the information technology. The plasma-material interaction is also one of the key issue for realization of nuclear fusion power plant which confines high-temperature plasma of 100 million degrees Celsius with magnetic field or inertial force.

Various plasma-material interaction mentioned above is investigated by comparing molecular simulation with plasma experiments, in our lab.

Appealing point:

We can provide knowledge to understand macroscale phenomena related to plasma-material interaction from the atomic scale by largescale molecular dynamics simulations using supercomputers.

Yamagata University Graduate School of Science and Engineering Research Interest : Plasma-material interaction

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